

# WG4

Injector and beam  
manipulation concepts (low  
emittance  $e^+$  and  $e^-$  sources, emittance  
exchange, reduction and preservation  
approaches, ...)

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Special assistance from Martin

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# Requirements for Injectors

TABLE 1). Major parameters of the sources.

Parameters	ILC	CLIC	Laser-Dielectric	PWFA	coaxial_DLA	LWFA
Particle Type	e-,e+	e-,e+	e-,e+	e-,e+	e-,e+	
Particles Per $\mu$ bunch	$2 \times 10^{10}$	$6 \times 10^9$	$6 \times 10^4$	$1 \times 10^{10}$	$2.5 \times 10^7$ (4pC)	
Number Of $\mu$ bunch	2625	312	100-300	125	$45 \times 10^3$	
Width Of $\mu$ bunch	1 ns (~ps)	100 ps(~ps)	100 attosec	33 fs	30 ps	
Time Between $\mu$ bunches	360 ns	500.2 ps	6.7 fs	4 ns	330 ps	
Peak Current of $\mu$ bunch	4.8 A	9.6 A	67 A	45 kAmps?	0.12 A	Peak Current of $\mu$ bunch
Width Of Macropulse	1 ms	156 ns	1 ps	500 ns	15 us	
Macropulse Repetition Rate	5 Hz	50 Hz	25 MHz	100 Hz	50 Hz	
Charge Per Macropulse	12600 nC	300 nC	1.6 pC	187 nC	180 nC	
Macropulse Current	12.6 mA	1.9 A	0.7 A	0.38 A	0.012 A	
Polarization (e-)	>80%	>80%	>80%	injector can provide it, but can plasma preserve it	80%	
Norm. Emittance, injected	$1 \times 10^{-3}$	$1 \times 10^{-3}$	no damping required for e-, problem for e+!		?	
Norm. Emittance, delivered (x/y)	$1 \times 10^{-5} / 4 \times 10^{-8}$	$6 \times 10^{-7} / 2 \times 10^{-8}$	$1 \times 10^{-10} / 1 \times 10^{-10}$	$0.2 \times 10^{-5} / 5 \times 10^{-8}$	?	
Power Source Wavelength	23 cm	2.5 cm	2 micron	200 um (not quite sine, nonlinear)	10 cm	
charge per second others??	42 uC	15 uC	40 uC	20 uC	9 uC	

\*All schemes still need similar beam power:  
polarization and e+ still needed at the same level

# Novel Concepts with Potential Benefits

- **Sources for microwave accelerators**

- Development of GaAs in SRF guns
- Development of high-voltage pulsed DC guns
- Emittance exchange
- Robust GaAs
- Field Emitter Array cathode

Lower emittance

Stable operation

- **Sources for optical accelerators**

- Single tip tungsten laser assisted
- Pyroelectric crystal e- source

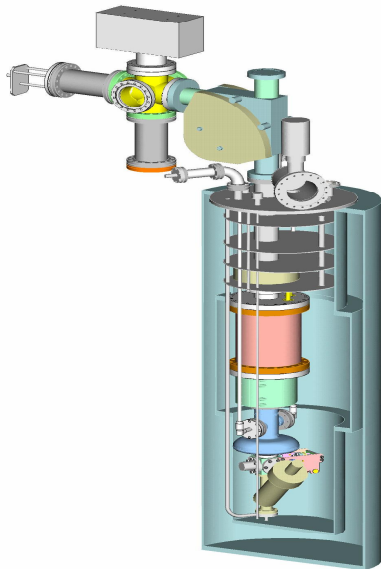
New injectors to match  
Into optical accelerators

# Concepts to lower emittance

Benefits: ease or eliminate damping ring

## GaAs in SRF guns

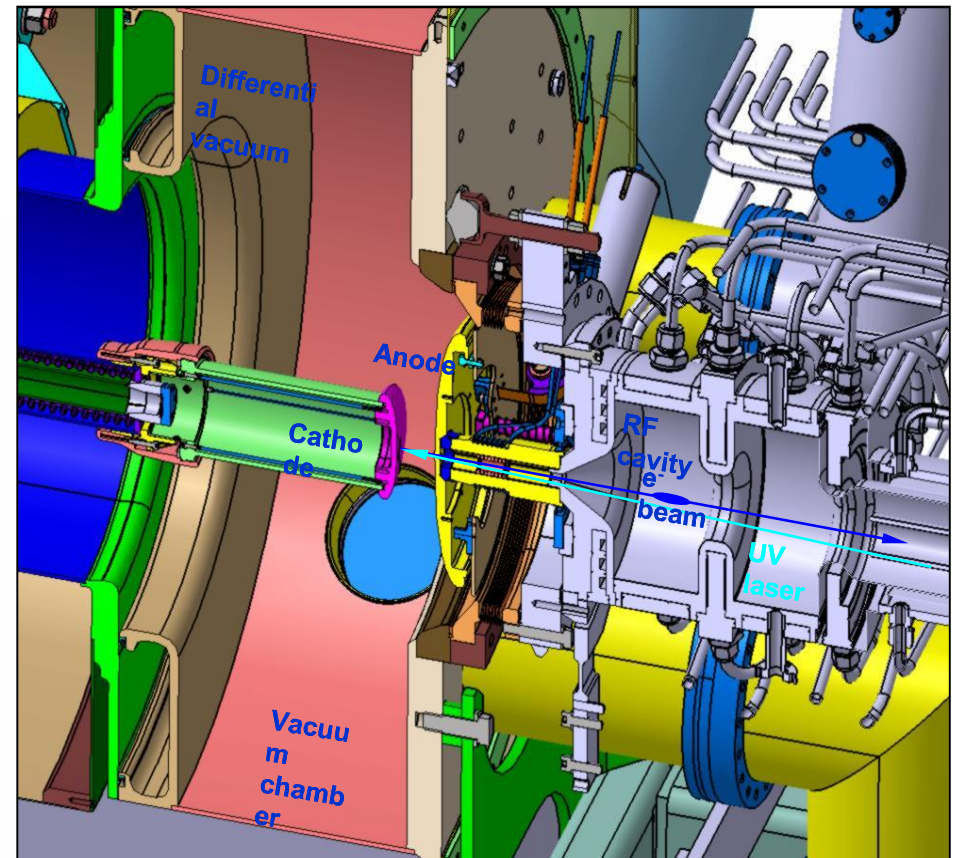
- Polarization
- QE ~ 0.5%
- eN ~ 0.3 um
- Test scheduled for next month



high-voltage pulsed DC guns

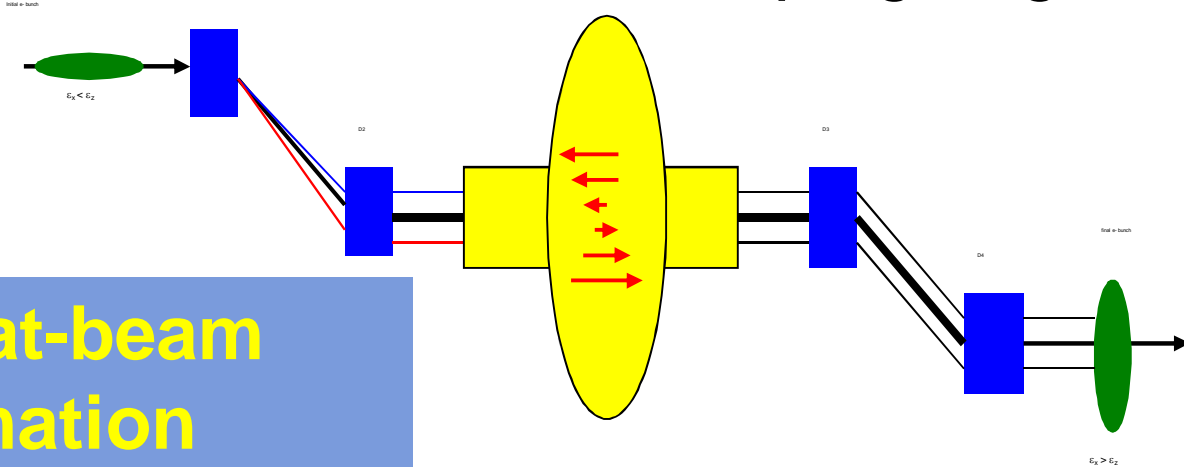
-500 kV

-lower eN possible (0.5um?)

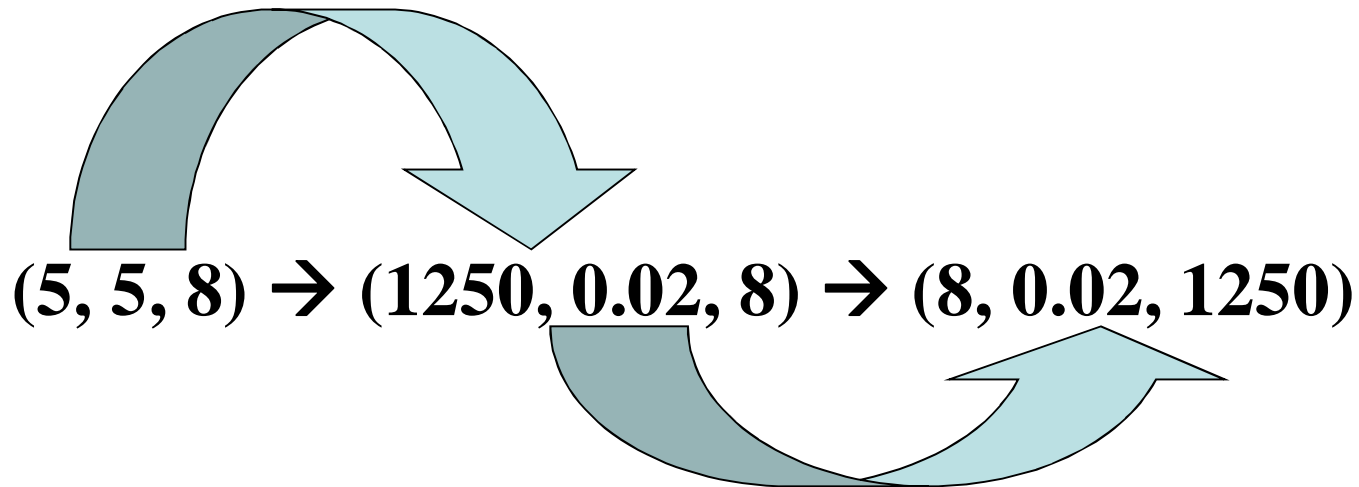


# Concepts to lower vertical emittance

Benefits: ease or eliminate damping ring



**round-to-flat-beam transformation**



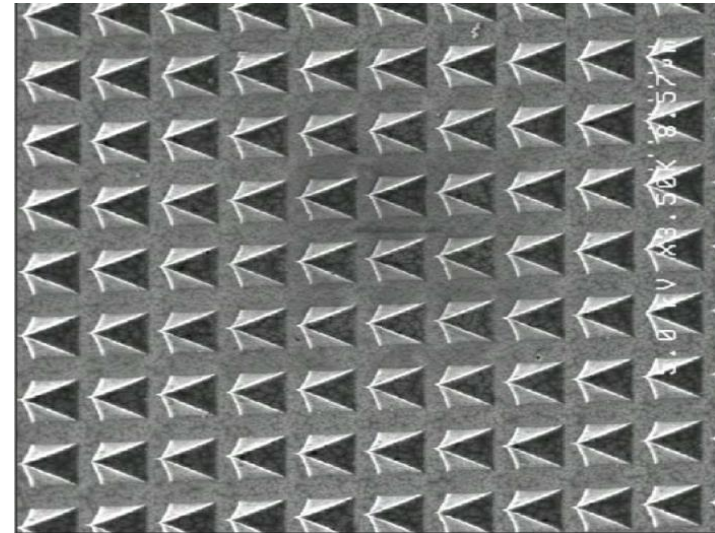
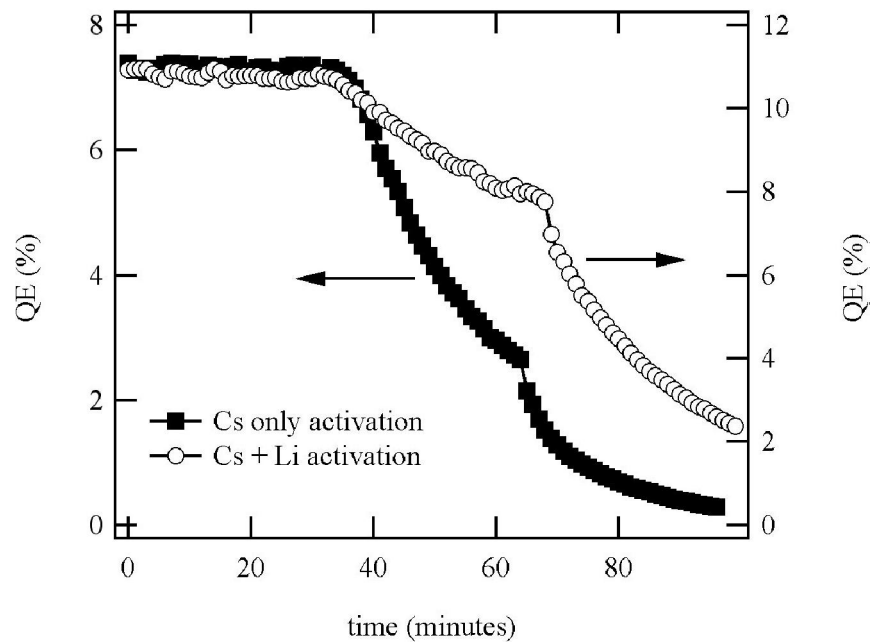
**Emittance exchange**

# Concepts to stability

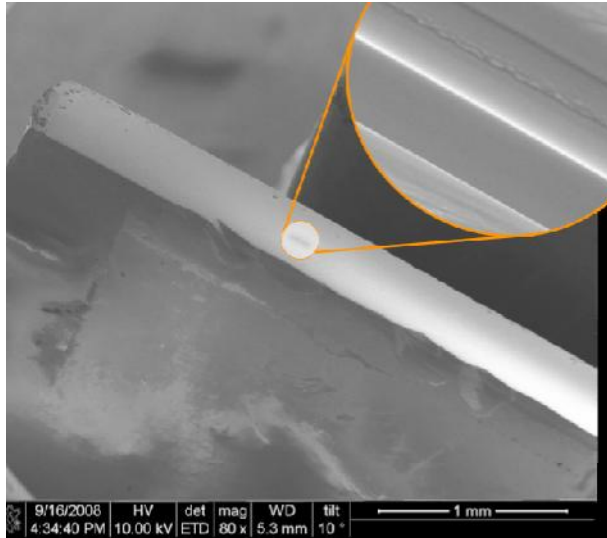
## Benefits: lower cost

**Field Emitter Array cathode**  
-eliminate the need for the laser  
-potential for lower emittance

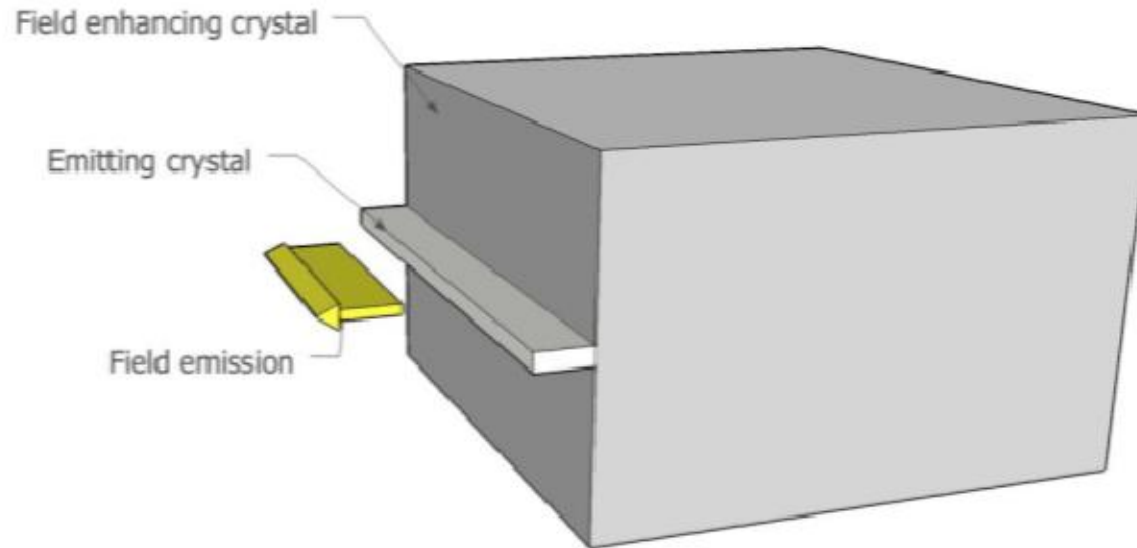
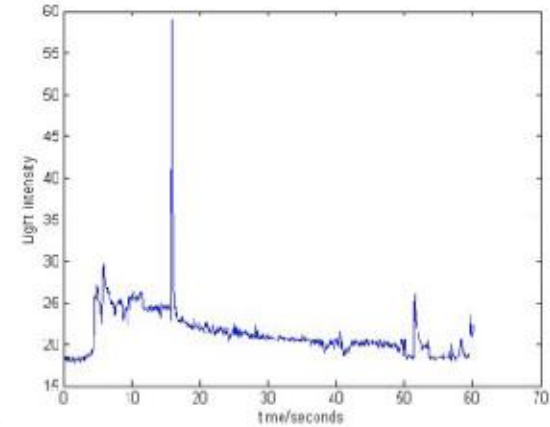
**Robust GaAs**  
-longer lifetime x2?



# Concepts for optical wavelength injectors

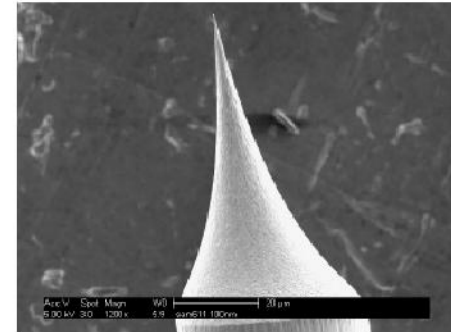
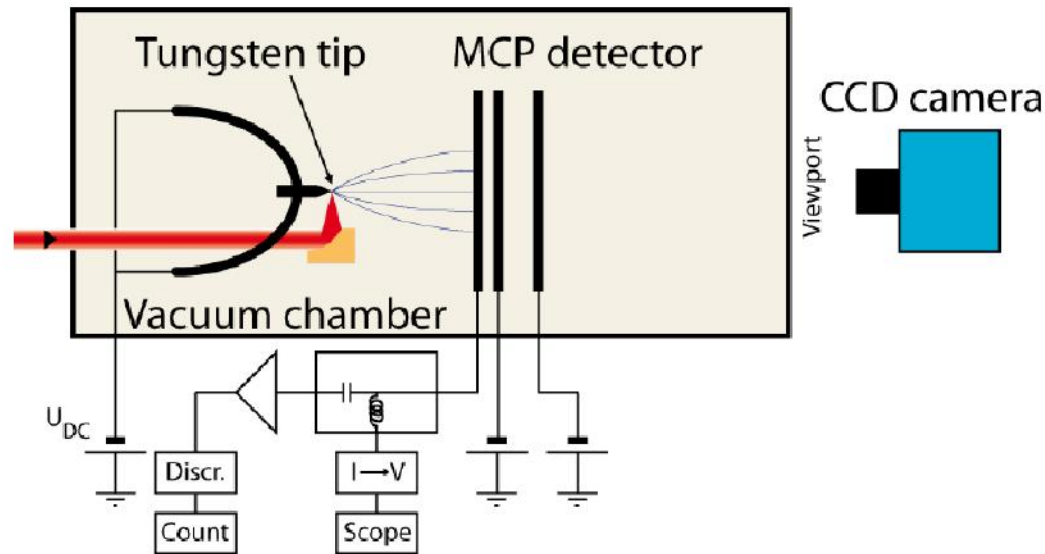


**Pyroelectric crystal**  
-100 um emitter

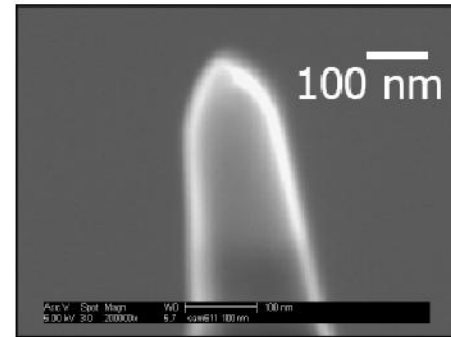


# Concepts for optical wavelength injectors

## Experimental setup



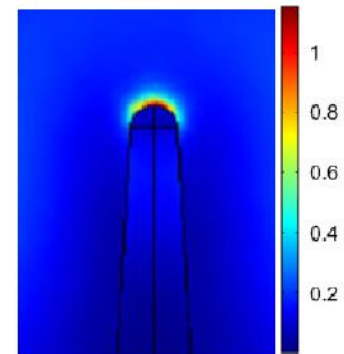
125  $\mu\text{m}$



100 nm

- Ti:Sa oscillator:  $\sim 780\text{nm}$ , 500mW, 6fs, 150MHz
- Spot radius on tip  $\sim 3 \mu\text{m}$  ( $1/e^2$ )
- Peak elec. field up to 5GV/m w/o field enh.

$r=50 \text{ nm}$  W tip,  
780 nm light





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